

Remarks

1. Amendment of the specification:

- 5 The main feature of the present invention is forming
a thin film transistor with two dielectric layers
thereon. Some typos and improper descriptions are
corrected in the amended specification. No new matter
is introduced in the above-mentioned amendment.
- 10 Allowance for making the above-mentioned amendment is
politely requested.

2. Amendment of claims 1 and 4:

- 15 Claim 4 is combined to claim 1 and therefore
cancelled. No new matter is introduced in the
above-mentioned amendment. Allowance for making the
above-mentioned amendment is politely requested.

20 3. Amendment of claims 1, 2, 7, 8, 11, and 12:

- Claims 1, 2, 7, 8, 11, and 12 are amended to be
identical with the amended descriptions in the
specification. No new matter is introduced in the
above-mentioned amendment. Allowance for making the
above-mentioned amendment is politely requested.

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Sincerely yours,

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